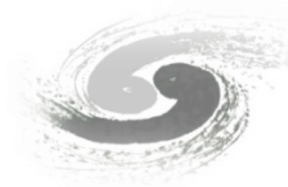


# Performance of the Low Gain Avalanche Diodes after irradiation developed by NDL and IHEP in China

36th RD50 Workshop (CERN - - online Workshop)

Yunyun Fan on behalf of IHEP HGDT group

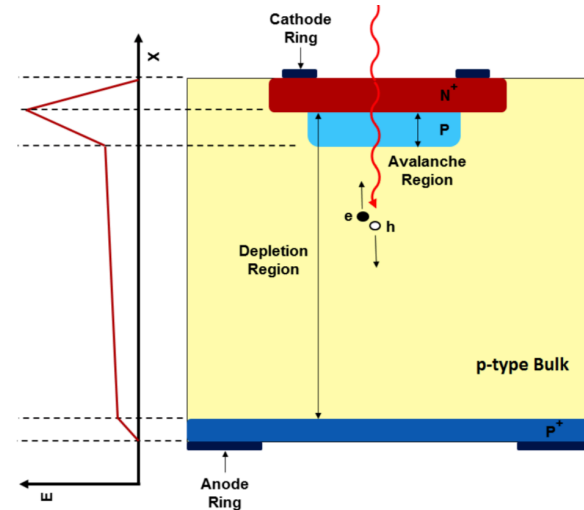
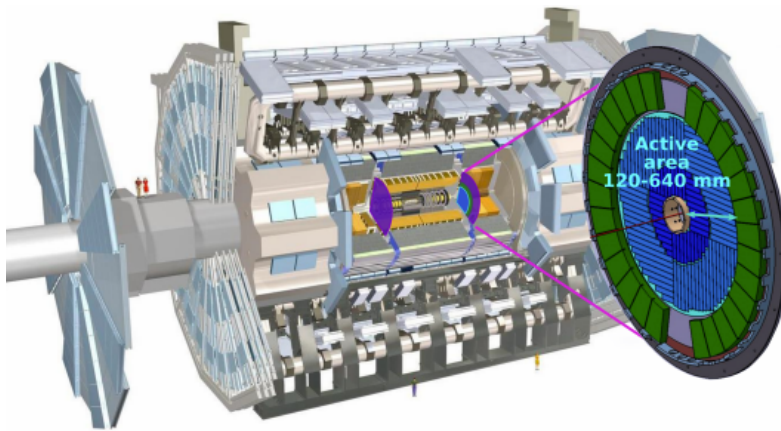
2020.6.4



- **Introduction to HGTD and IHEP-NDL LGAD**
- **Irradiation study**
  - X ray irradiation
  - Neutron irradiation
- **Summary**



- **High-granularity timing detector (HGTD)**
  - For **ATLAS** phase II upgrade to reduce pile up
  - Employ the Low Gain Avalanche Diode (LGAD) technology



- **Radiation hardness ATLAS requirements**

LGAD sensors after radiation :  $2.5 \times 10^{15} N_{eq} / \text{cm}^2$  and **2 MGy**

- Timing resolution : **< 70 ps**
- Collected charge: **> 4 fC**
- Leakage current per pad: **< 5  $\mu\text{A}$**



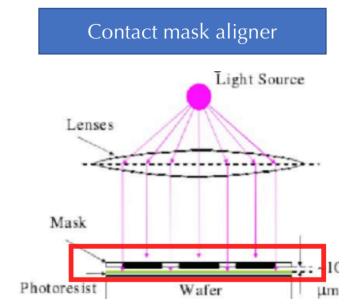
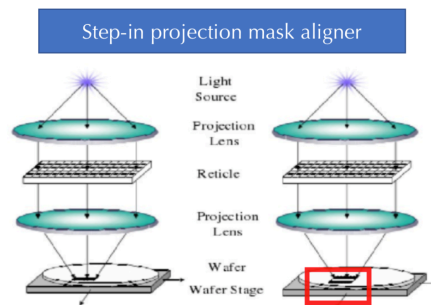
- **Atlas LGAD Foundry:**

CNM (Spain),HPK (Japan),FPK (Italy), BNL (US) ,**IHEP-NDL (from China)**

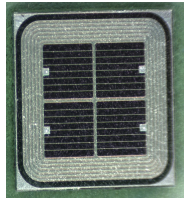
- **IHEP cooperatea with Novel Device Laboratory (NDL) in the early 2019**

- **Introduction to NDL:**<http://www.ndlsipm.net/contacteng.html>

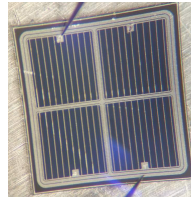
- Foundry for SiPM.
- Thickness of epitaxial layer: 33um
- Epitaxial layer Resistivity: 100 Ohm.cm or 300 Ohm.cm
- Have both contact mask and step-in projective mask machine. step-in for 2 x 2 LGAD sensors, contact mask for 15 x 30 LGAD sensors



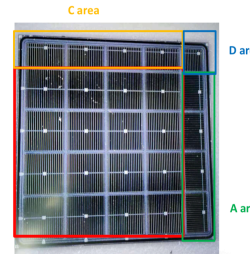
- Three batches LGAD sensor fabricated in one year (2019).



1<sup>st</sup> Batches



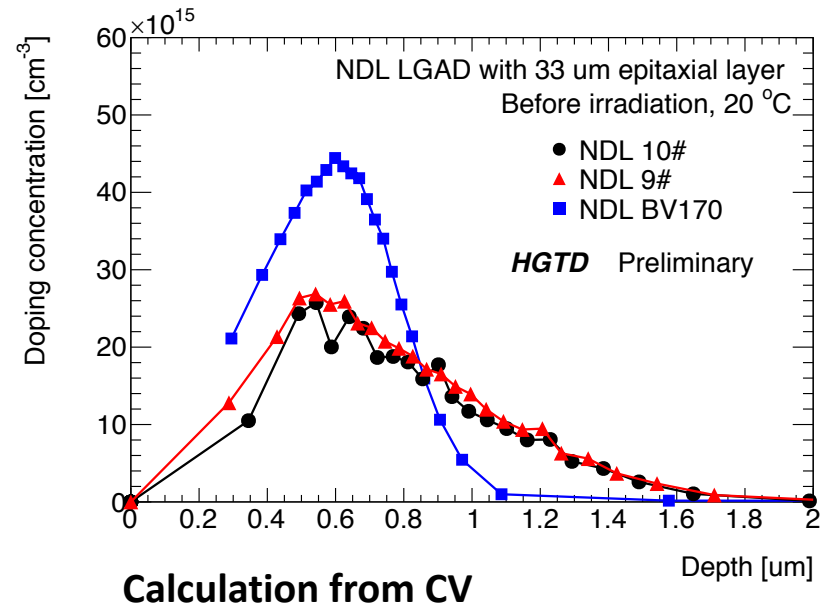
2<sup>nd</sup> Batches



2<sup>nd</sup> Batches:

## Parameters of the Batches

- Epitaxial layer: **33  $\mu\text{m}$**
- Different wafer resistivity : **100  $\Omega\cdot\text{cm}$  , 300  $\Omega\cdot\text{cm}$**
- Guard ring: **grounded , floating**
- Different doping profile



- Introduction to HGTD and IHEP-NDL LGAD
- **Irradiation study**
  - X ray irradiation
  - Neutron irradiation
- **Summary**



# Irradiation Campaign

- **Total ionization dose (TID) study for ND L LGAD sensors**
  - X ray irradiation experiment at IHEP, TID up to 100kGy
  - Irradiation machine: MutlRad160
  - Dose rate: 174 Gy/min

X-ray irradiation machine

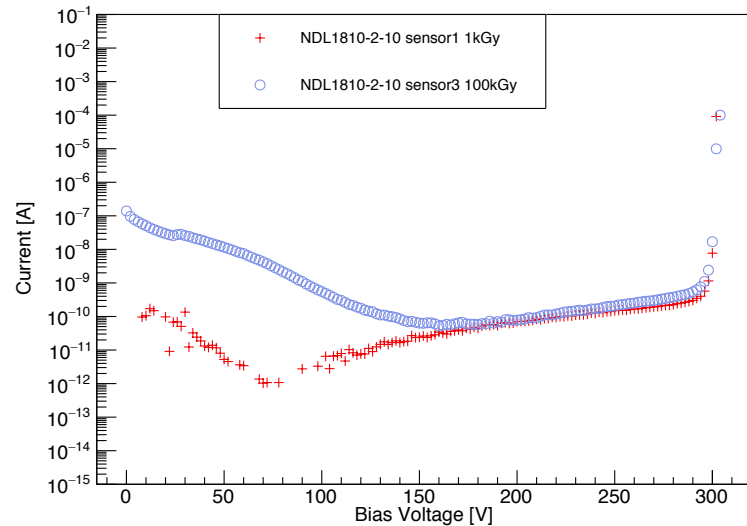
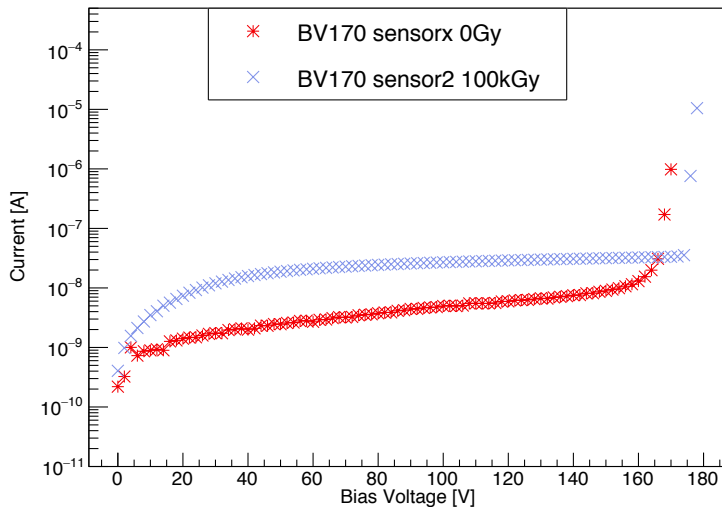


- **In the future**, the TID dose will accumulate up to 2 MGy



## ➤ NDL sensors

Leakage current for NDL BV170 is **0.5  $\mu\text{A}$**  and NDL #10 is lower than  **$1 \times 10^{-3} \mu\text{A}$** . The leakage current of the rests is about **1  $\mu\text{A}$** .

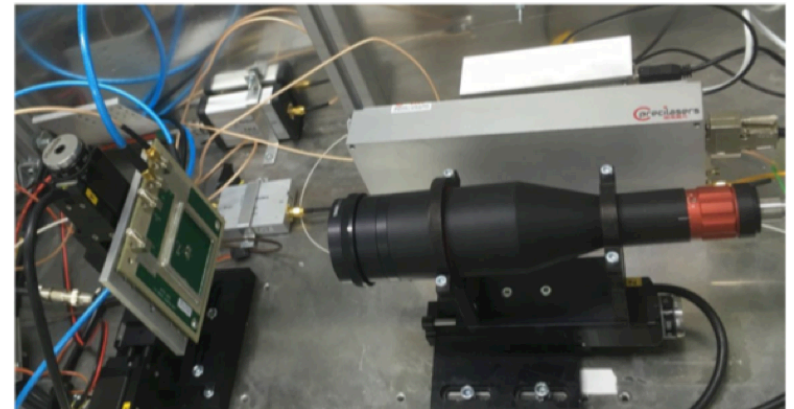
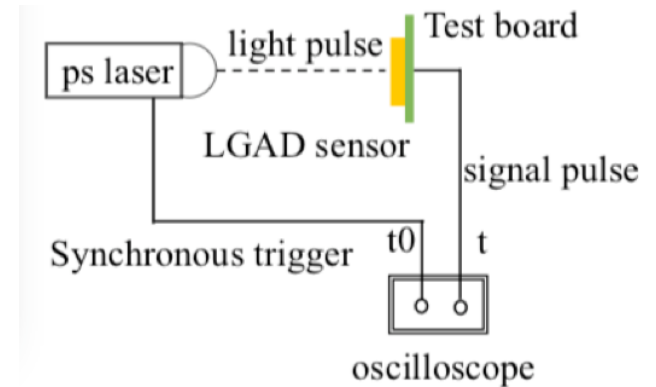
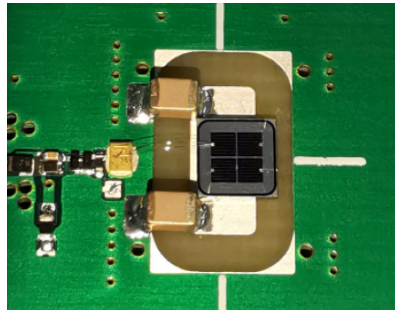




- **Testing timing response for NDL LGAD sensor with TCT laser system**
  - Replace the TCT laser with pico-second pulse laser
  - pico-second Laser Pulse width : 7ps; wavelength: 1064nm, , Frequency: 20MHz
- **Evaluate the jitter contribution**
  - Less than 10ps
  - Laser power is larger than MIP

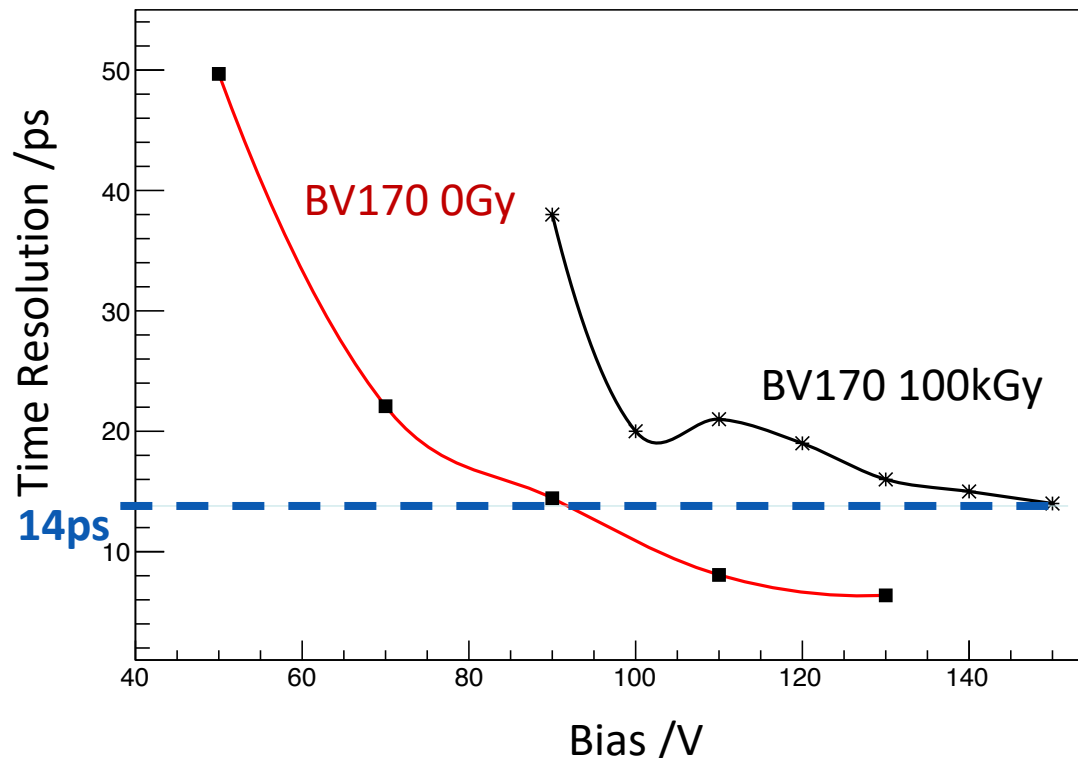
$$\sigma_t^2 = \sigma_{TimeWalk}^2 + \sigma_{LandauNoise}^2 + \sigma_{Distortion}^2 + \sigma_{jitter}^2 + \sigma_{TDC}^2$$

Wirebond one pixel  
to UCSC single channel board



# Time Resolution from Laser Test

- **After 100kGy**
  - The timing resolution contributed from jitter is about 14 ps
  - The time resolution have a potential to satisfy the request 70 ps



- Introduction to HGTD and IHEP-NDL LGAD
- **Irradiation study**
  - X ray irradiation
    - **Neutron irradiation**
- Summary



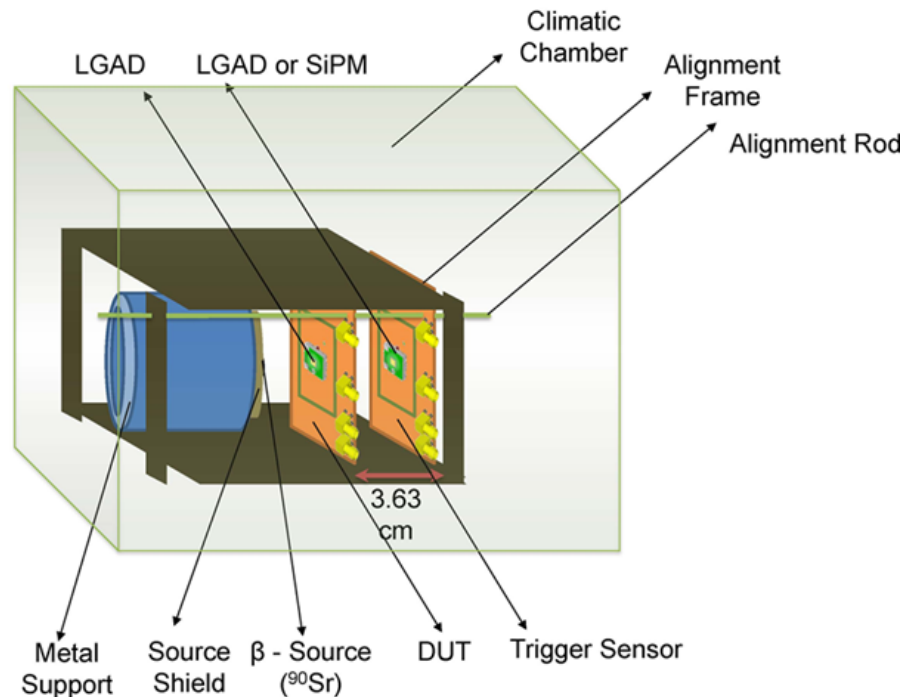
- **Non-ionization damage study on LGAD sensor with neutrons**
  - Reactor neutrons: TRIGA research reactor of the the **Jozef Stefan Institut (JSI)** in Ljubljana
  - Fluence up to  **$2.5 \times 10^{15} \text{ n}_{\text{eq}}/\text{cm}^2$**  (1 MeV equivalent neutrons per cm<sup>2</sup> )
- **Annealing:** after irradiation, the devices were annealed for 80 min at 60 °C



- **Beta test (time resolution , collected charge)**

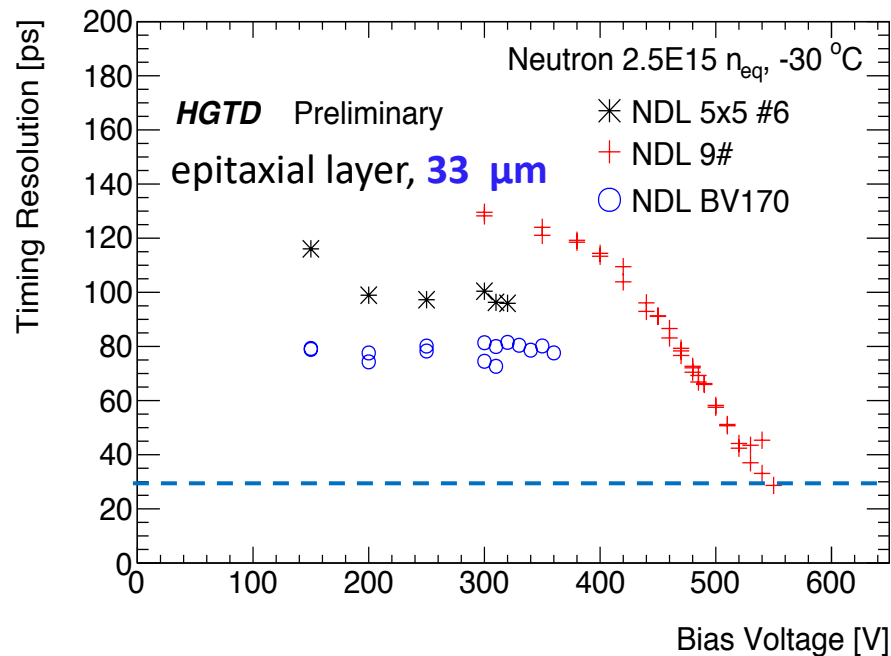
**Done by UCSC**

- Electrons by Sr90 Beta source
- Single channel board developed by UCSC
- Fast amplifier with bandwidth >1GHz



# Timing Resolution

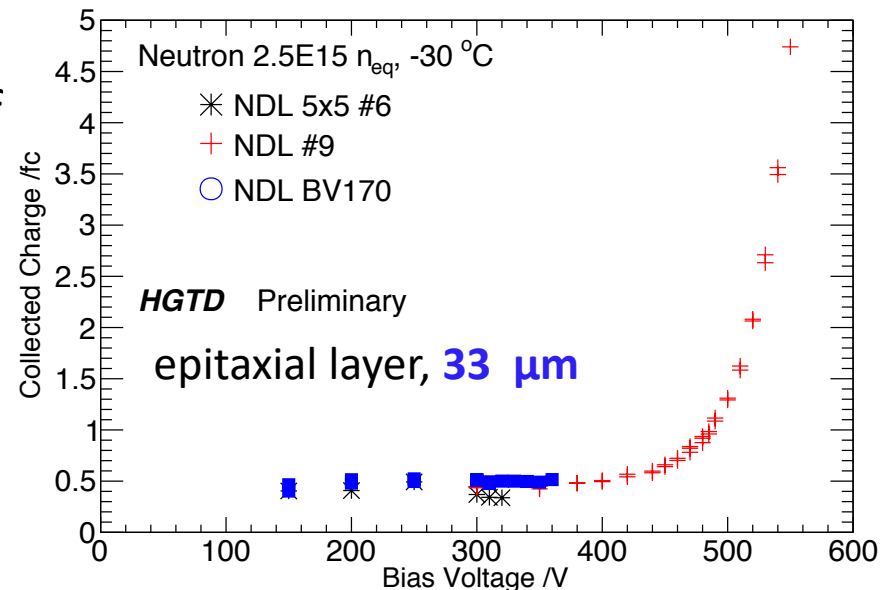
- **NDL #9**: 30 ps at about 562 V, 35 ps at 550 V (**satisfy the requirement of ATLAS, < 70 ps**)
- **NDL 5 × 5 #6** and **BV170** : best timing resolution : ~ 96 ps, ~ 74 ps
- The better timing resolution of 9# was most possible due to **higher wafer resistance** (300 Ω·cm). BV170 and NDL #6 (100 Ω·cm)



# Collected Charge

- **NDL #9** : collected charge is close to 4 fC at 550 V. ( **more study on noise in high Voltage bias is on going**)
- **NDL 5 × 5 #6 and BV170**: best collected charge is ~0.4 fC, ~ 0.6 fC
- **Reason for the better performance of NDL #9** is considered to be the higher wafer resistivity (300  $\Omega \cdot \text{cm}$ ), BV170 and NDL #6 ( 100  $\Omega \cdot \text{cm}$ )
- **To improve the collected charge in the future**
  - The thicker epitaxial layer, **50  $\mu\text{m}$** , will be used
  - the **Carbon** would be done by cooperating with the Institute of Microelectronics (IME) in China

<http://english.ime.cas.cn>



- Introduction to HGTD and IHEP-NDL LGAD
- Irradiation study
  - X ray irradiation
  - Neutron irradiation
- **Summary**





- **Irradiation hardness of NDL has been tested**
  - Verify that satisfies the ATLAS requirement until **100kGy**
  - After neutron irradiation up to  **$2.5 \times 10^{15} \text{ n}_{\text{eq}}/\text{cm}^2$** 
    - The timing resolution of 33 NDL #9 could be **~35 ps** satisfy the ATLAS requirements  $< 70 \text{ ps}$
    - Collected charge is **close to 4 fC at 550 V**. ( more study on noise in high Voltage bias is on going)
- **Radiation hardness of NDL sensor with high resistivity (300  $\Omega\cdot\text{cm}$  ) is better than those with lower resistivity (100  $\Omega\cdot\text{cm}$ ).**
- **In the future**
  - TID dose will be accumulate up to 2 MGy
  - Increase the thickness of epitaxial layer: **33  $\mu\text{m}$  -> 50  $\mu\text{m}$**
  - Carbon to increase the radiation hardness



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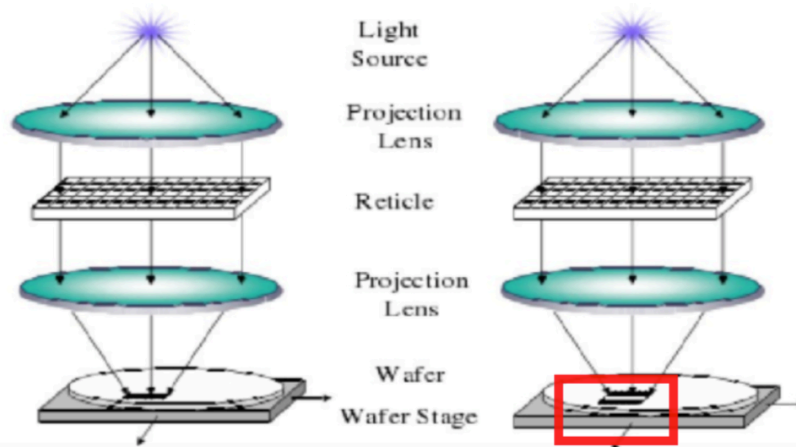
**Thank you for your  
attention !**



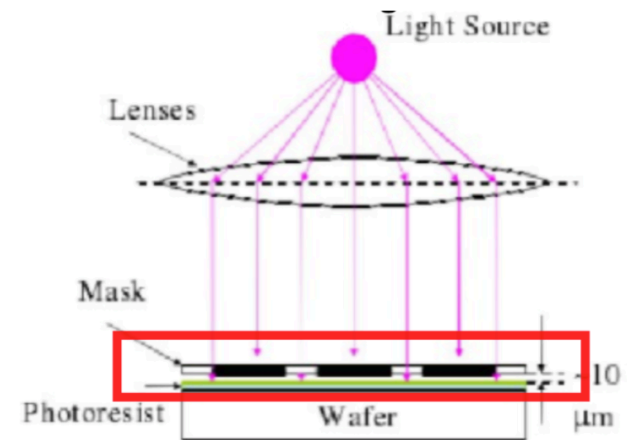
- 
- **Back up**

- Foundry working with DNL have both contact mask and step-in projective mask machine
- NDL used step-in projection mask aligner for small sensor sensors (2x2cm reticle size)
- Will switch to contact mask aligner for larger sensor (15x30 LGAD or even larger sensors)
  - Similar mask technology as CNM or HPK
  - Layout in full wafer size, not limited by reticle size

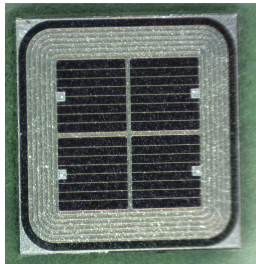
### Step-in projection mask aligner



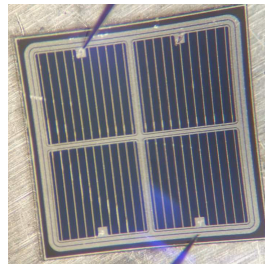
### Contact mask aligner



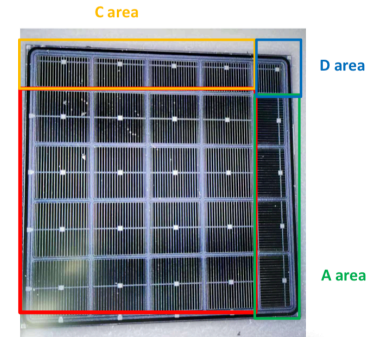
- Three batches LGAD sensor fabricated in one year( 2019).



1<sup>st</sup> Batches



2<sup>nd</sup> Batches



3<sup>rd</sup> Batches:

Bathes	Sensor Type	VBD (V)	V_Depleted (V)	Layout	Wafer ( $\Omega$ .cm)	Gain
1 <sup>st</sup>	BV170	~165	~100	6GR	100	40
	BV60	~95	~40	6GR	300	40
2 <sup>nd</sup>	10#	~300	~40	2GR	300	80
	9#	~250	~40	2GR	300	80
3 <sup>rd</sup>	NDL 5x5 6#	~400	~120	2GR	100	10~20
	NDL 5x5 12#	~390	~35	2GR	300	10~20

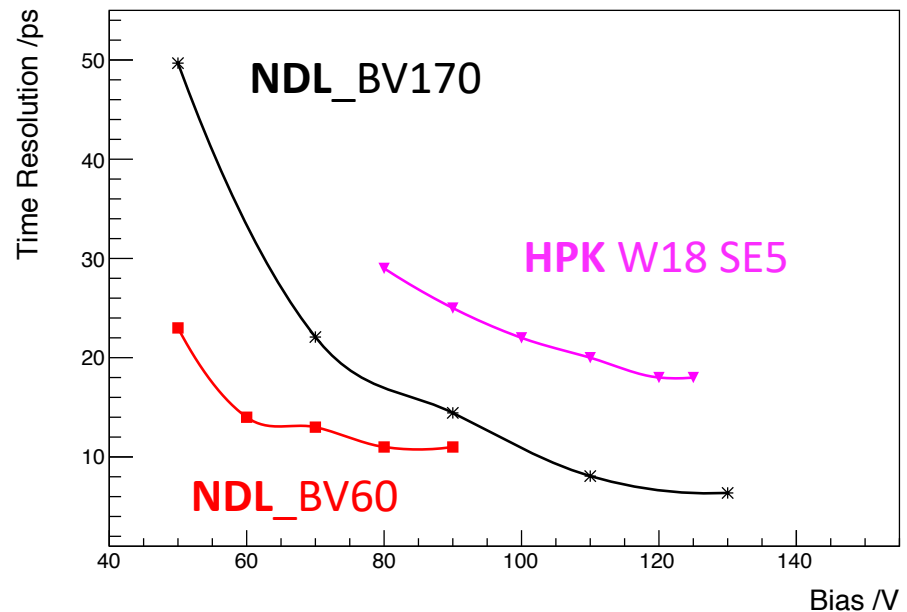
$$\sigma_t^2 = \sigma_{TimeWalk}^2 + \sigma_{LandauNoise}^2 + \sigma_{Distortion}^2 + \sigma_{Jitter}^2 + \sigma_{TDC}^2$$

## ■ Laser test:

- no Landau fluctuation, ~ps Laser
- Help to understand the jitter

## ■ Preliminary results

- The time resolution of NDL is from 3~50 ps
- Better than HPK W18 SE5



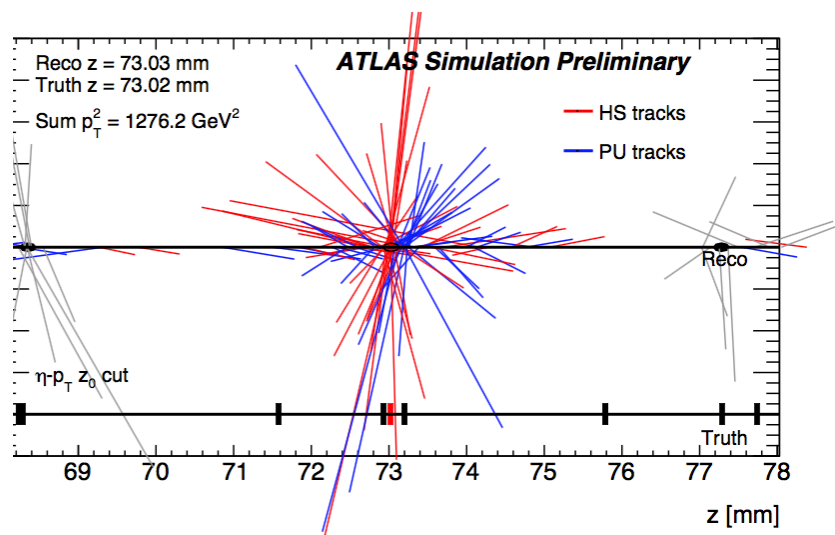
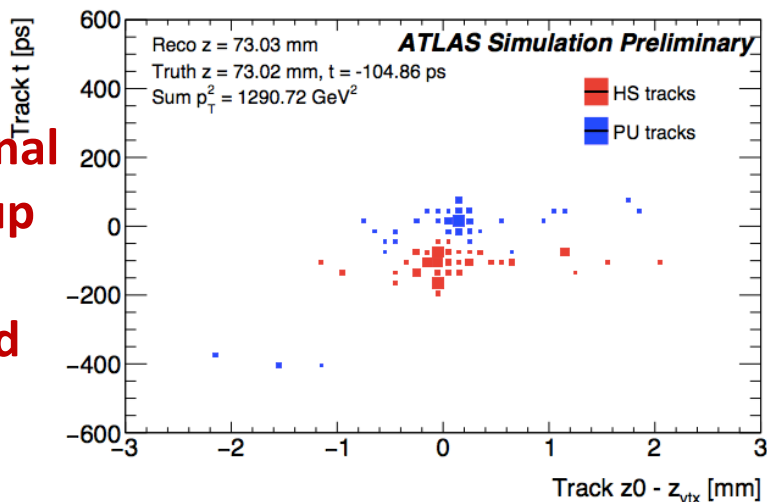
- **Pileup is the major challenges at HL-LHC**
  - Track from different vertexes close in space, but well-separated in time.
  - Explore the spread of the collision to reduce pileup background by timing
  - Need **30ps timing resolution** to reduce the pileup background by a factor of 6
- **Significant impact on some physics case**

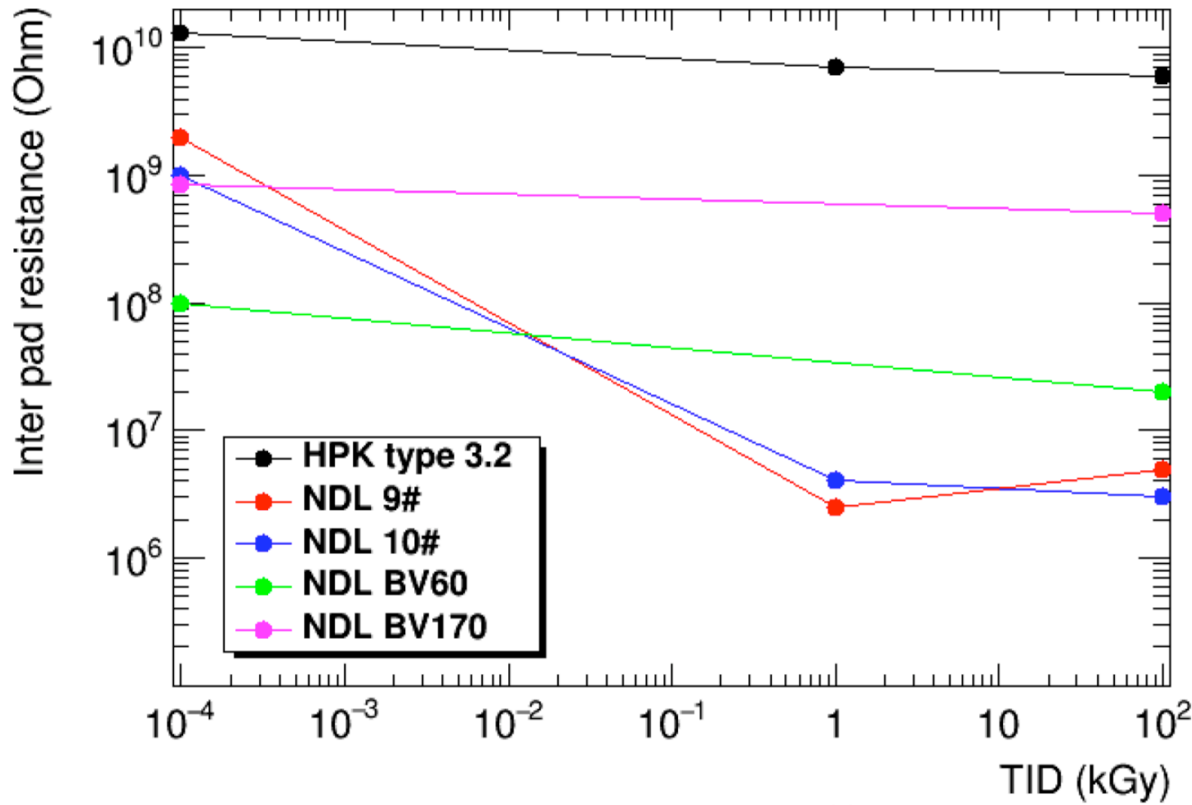
100Ω.cm

  - VBF Higgs, Weak mixing angle measurement

Higgs signal and pileup are separated in time !

Yun





After irradiation  
decrease:

NDL 10# > NDL 9# >  
HPK T 3.2 > NDL BV170

